## Printed by EAST

UserID: JChen1

Computer: WS04794

**Date:** 06/30/2000

**Time:** 19:59

					i i		<u> </u>	Error	Err
Туре	<b>A</b> \	뉴 #	Hits	Search Text	DBS	Time Stamp		Definition	ors
BRS		L1	6550	floating adj gate\$1	USPAT	2000/06/30 19:01			0
BRS		1.2	13690	control adj gate\$1	USPAT	2000/06/30 19:01			0
BRS		Г3	4230	1 and 2	USPAT	2000/06/30 19:01			0
BRS		L4	6771	(polish\$ or CMP or (chemical adj mechani\$ adj polish\$)) near15 (insulat\$ or oxide or dioxide or nitride or isolat\$)	USPAT	2000/06/30 19:19	Tr Ov Se Se	Truncation Overflow. Return String from Server is: 5.0.0.POL	
BRS		L5	113	3 and 4	USPAT	2000/06/30 19:57			0
BRS		L6	12767	(oxide adj2 nitride adj2 oxide) or ONO	USPAT	2000/06/30 19:23			0
BRS		L7	73	5 and 6	USPAT	2000/06/30 19:24			0
BRS		- T-8	2705	(high adj quality adj oxide) or (high adj temperature adj oxide) or HTO or ((LPCVD or (low adj pressure adj chemical adj vapor adj deposit\$)) near10	USPAT	2000/06/30 19:31			0
BRS		L9	8	7 and 8	USPAT	2000/06/30 19:32			0
IS&R	<u>~</u>	L10	745	(("438/259") or ("438/257") or ("438/263") or ("438/264") or ("438/265") or ("438/266")).CCLS.	USPAT	2000/06/30 19:59			0
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Type	ي م	#	Hits	Search Text	DBs	Time Stamp	Co mm Error en Definition ts		Err
BRS		L1	6550	floating adj gate\$1	USPAT	†·····		0	
BRS		L2	13690	control adj gate\$1	USPAT	2000/06/30 19:01		0	
BRS		L3	4230	1 and 2	USPAT	2000/06/30 19:01		0	
BRS		L4	6771	(polish\$ or CMP or (chemical adj mechani\$ adj polish\$)) near15 (insulat\$ or oxide or dioxide or nitride or isolat\$)	USPAT	2000/06/30 19:19	Truncation Overflow. Return string from Server is: 5.0.0.POL	_ E	
BRS		L5	113	3 and 4	USPAT	2000/06/30 19:22		0	
BRS		L6	12767	(oxide adj2 nitride adj2 oxide) or ONO	USPAT	2000/06/30 19:23		0	
BRS		17	73	5 and 6	USPAT	2000/06/30 19:24		0	
BRS		L8	2705	(high adj quality adj oxide) or (high adj temperature adj oxide) or HTO or ((LPCVD or (low adj pressure adj chemical adj vapor adj deposit\$)) near10	USPAT	2000/06/30 19:31		0	
BRS		L9	ω	7 and 8	USPAT	2000/06/30 19:31		0	